

Claims:

1. A layer, wherein the layer is obtained by thermal treatment from an aqueous dispersion applied to a substrate, the dispersion containing silicon/titanium mixed oxide powder prepared by flame hydrolysis.
2. A layer as claimed in claim 1, wherein the thickness of the layer is between 100 nm and 1 mm, preferably between 1 μ m and 50 μ m, particularly preferably between 5 μ m and 15 μ m.
3. A layer as claimed in claim 1 or 2, wherein the BET surface area of the powder is between 5 and 500 m²/g.
4. A layer as claimed in claims 1 to 3, wherein the titanium dioxide content of the powder is between 0.1 and 99.9 wt.%, particularly preferably between 2 and 20 wt.%.
5. A layer as claimed in claims 1 to 4, wherein it contains a mixture of powders with high BET surface areas of at least 170 m²/g and those with low BET surface areas of at most 70 m²/g, preferably with high BET surface areas of at least 130 m²/g and those with low BET surface areas of at most 90 m²/g, wherein the ratio by weight of powder with lower to powders with higher BET surface areas is between 40:60 and 99.5:0.5.
6. A process for preparing the layer as claimed in claims 1 to 5, wherein a dispersion is applied to a substrate, the dispersion containing silicon/titanium mixed oxide powder, and this is subsequently sintered by thermal treatment.
7. A dispersion prepared by using silicon/titanium mixed oxide powder prepared by using flame hydrolysis, wherein the proportion of powder is between 0.1 and 60 wt.%.

8. Use of the layer as claimed in claims 1 to 4 for use in composite materials with materials with very low coefficients of expansion (ultra-low expansion, ULE, materials), for photocatalytic applications, as coatings for self-cleaning mirrors (superhydrophilic constituents), for optical items such as lenses, as seals for gases and liquids and as mechanical protective layers.